

Fabrication Guidelines: RT/duroid® 6202PR High Frequency Laminates

Material Description: RT/duroid® 6202PR high frequency laminate is a ceramic filled, woven glass reinforced polytetrafluoroethylene (PTFE) composite. This extension to our highly successful RT/duroid 6002 and 6202 products provides the electrical performance essential for high frequency applications, possesses the thermal attributes necessary for reliable stripline and multilayer board constructions, and has mechanical properties that contribute to high yields through complex circuit board processes. RT/duroid 6202PR is available with standard electrodeposited and rolled copper foils, but is especially compatible with subtractively processing resistive foils. Customers have demonstrated resistor tolerances approaching +/- 5% when designing on RT/duroid 6202PR clad with foils from Ohmega Technologies.

These guidelines were developed to provide fabricators with basic information on processing stripline assemblies and multilayer boards using copper clad RT/duroid 6202PR. Processing information specific to resistive foils can be found at www.ohmega.com. For more information specific to substrate or resistive foil processing, please contact your Rogers' technical service or sales representative.

Storage: RT/duroid 6202PR cores can be stored indefinitely at ambient conditions. A FIFO inventory system is recommended as is a method of record keeping that would allow tracking of material lot numbers through PWB processing and delivery of finished circuits.

INNER LAYER PREPARATION:

Tooling: RT/duroid 6202PR is compatible with many tooling systems. Choosing whether to use round or slotted pins, external or internal pinning, standard or multiline tooling, and pre- vs. post-etch punching would depend upon the capabilities and preferences of the circuit facility and the final registration requirements. In general, slotted pins, a multiline tooling format, and post-etch punching will meet most needs. Whichever approach is used, it is good practice to retain copper around tooling holes.

A flow pattern compatible with the chosen adhesive system can be used between circuits and around the perimeter of the panel. But, in general, registration of layers (especially thin cores) is improved by retaining as much copper as possible.

Surface Preparation for Photoresist Application: A chemical process consisting of organic cleaners and a microetch is the preferred method of preparation of copper surfaces prior to coating with liquid or film photoresists. A conveyORIZED spray system using an abrasive substance suspended in solution can be used to prepare copper surfaces at the slight risk of some registration control. Mechanical scrubbing should be considered for thick cores (0.060" +) only and, even then, should be performed at reduced pressures.

Photoresist Application: RT/duroid 6202PR materials are compatible with most photoresist systems.

DES Processing: Developers and strippers compatible with the photoresist system of choice should be used. RT/duroid 6202PR materials are compatible with any copper etching system. However, materials clad with resistive foils should be etched using recommendations made by the suppliers of the special foil types.

Oxide Treatment: RT/duroid 6202PR is compatible with most oxide and oxide alternative processes. It is best to use the process recommended by the supplier of the adhesive system chosen to bond together the multilayer board, as long as that process is compatible with recommendations made by suppliers of the resistive foils.

BONDING:

Final Preparation: Special pretreatments of etched surfaces using sodium or plasma processes shouldn't be necessary provided care was taken to protect the substrate surface after copper etch. Inner-layers should be baked at 120-150°C for 30-120 minutes to ensure removal of volatile substances prior to MLB bonding. Guidelines for the oxide treatment and the resistive foils (if used) should be referenced for optimum bake conditions.

Multilayer Adhesive System: RT/duroid 6202PR materials are compatible with a broad range of thermosetting (FR-4, RO4400™, etc.) and thermoplastic (3001 bonding film, FEP, ULTRALAM® 3908, PFA, PTFE, etc.) adhesive systems. Many factors, such as electrical performance, flow characteristics, ease of processing, and bond temperature requirements are considered when making the best overall choice. Rogers' Technical Service Engineers (TSE's) understand the trade-offs and, if asked, will help in the selection process.

Multilayer Bond Cycle: The press cycle is determined by the requirements of the chosen adhesive system. Cooling under pressure is required when using thermoplastic (melttable) films.

PTH & OUTER LAYER PROCESSING

Drilling: Multilayers are most commonly drilled in stacks of one. Phenolic composite boards are recommended for entry (0.010" to 0.030" thick) and exit (>0.060") layers. Sheeted aluminum and metal coated phenolic boards can also be used as entry layers.

New carbide drills are highly recommended. Standard or undercut styles can be used. Recommended chip loads (0.001" to 0.003" per revolution) and surface speeds (150 to 300 SFM) vary with tool diameter with slower infeeds and speeds being associated with finer diameter drills. Retract rate when drilling multilayer boards should be between 300 and 500 IPM. Below is a quick reference table that provides recommended parameters for commonly used drill diameters.

Tool life should be based upon inspection of cross-sectioned holes. The "twelve inch rule," which suggests changing a tool after drilling 12" of substrate, is a good place to start. For example, initial hit count when drilling a 0.060" thick board would be $12"/0.060" = 200$ holes.

Tool Size		Spindle Speed (RPM)	Indeed		Retract	
(in)	(mm)		(IPM)	(m/min)	(IPM)	(m/min)
0.0079	0.20	72500	72.5	1.8	300	7.6
0.0098	0.25	68200	88.7	2.3	300	7.6
0.0138	0.35	55400	83.1	2.1	300	7.6
0.0197	0.50	48200	96.4	2.4	400	10.2
0.0256	0.65	37200	74.2	1.9	400	10.2
0.0295	0.75	32200	64.4	1.6	400	10.2
0.0394	1.00	24100	48.2	1.2	400	10.2
0.0492	1.25	20000	40.0	1.0	400	10.2
0.0625	1.59	20000	40.0	1.0	400	10.2
0.1250	3.18	20000	40.0	1.0	400	10.2

Deburring: The use of flat, rigid entry materials, conservative drilling parameters, and limited hit counts with new drills should minimize the risk of copper burring. When drilled properly, cores should be ready for subsequent processing. If debur is necessary (and slight), a chemical microetch process is preferred. If mechanical processing is required, a hand pumice scrub is preferred over a suspended abrasive spray system which, in turn, is preferred over a conveyORIZED mechanical debur or planarization process.

Hole Preparation: Loosely deposited debris in the holes can be removed using a vapor or hydro-honing process. These processes involve directing water suspended abrasive particles through drilled holes. The soft laminates must be properly supported through these processes.

Broken glass bundles can be removed using the process described above or dissolved using a glass etch process that is standard to most FR4 material chemical desmear processes.

Depending upon the adhesive system used (FR4, for example), a chemical or plasma desmear process may be required. These desmear processes will have little effect on the RT/duroid 6202PR materials and should be done prior to activation of the PTFE surface. The chemical process appropriate for desmear of the adhesive system can be used. CF4/O2 plasma can also be used. A dual plasma cycle to accomplish desmear of an adhesive system and activation of the PTFE surface is made possible by adding the desmear cycle outlined below to the front end of the treatment cycle described in the treatment portion of this section.

Frequency	40KHz
Voltage:	500-600V
Power:	4000-5000 Watts
Preheat to 60°C using:	
Gases:	90% O2M 10% N2
Pressure:	250 mTORR
Desmear using:	
Gases:	75% O2, 15% CF4, 10%N2
Pressure:	250mTORR
Time:	10-30 minutes

Drilled holes in PTFE-based laminates must be treated prior to the deposition of a conductive seed layer (e.g., electroless copper or direct metallization). Not performing a surface activation treatment will most likely result in poor metal adhesion or plated voids. Two common pre-treatments for PTFE materials are sodium treatment and plasma treatment. Either can be used for treating RT/duroid 6202PR materials.

Sodium treatment products and recommended application procedures are available from:

Poly-Etch	Fluoro-etch
Matheson Gas Products 61 Grove Street Gloucester, MA 01903 978-283-6177	Acton Associates Inc. 100 Thompson Street Pittston, PA 18640 570-654-0612

A recommended plasma cycle for treating PTFE materials is:

Gases:	0/30 or 80/20 H ₂ /N ₂ , NH ₃ , N ₂ , or He
Pressure:	00 mTORR pumpdown 50 mTORR operating
Power:	4000 Watts
Frequency:	40 KHz
Voltage:	500-600V
Cycle time:	10-30 minutes

Metallization: RT/duroid 6202PR materials are compatible with traditional electroless copper and direct deposit metallization processes. Cores should be baked (30-90 minutes @ 120-150°C) prior to metal deposition unless plasma, which also serves as a vacuum bake, was used to prepare the hole walls for plating. A flash plate build-up of 0.0001" to 0.0003" (0.0025mm-0.0076mm) of copper is recommended to better support hole walls through preparation for outer-layer processing.

PTH Plating & Outer-Layer Imaging: Standard equipment and chemical processes are used to plate, image, and etch circuit patterns onto RT/duroid 6202PR materials. Care should be taken to preserve the post-etch dielectric surface. The topography that remains after copper removal promotes improved adhesion to soldermasks. Materials should be rinsed and baked prior to soldermask application. Rinsing in warm or hot water for 20-30 minutes followed by 60 minutes at 125°C should be sufficient, especially if the bake is done under vacuum.

Final Surfaces: RT/duroid 6202PR materials are compatible with most LPI soldermasks. Epoxy soldermasks are preferred if the application requires selective silk screening. Most final metal surfaces (ENIG, Sn, Ag, Ni/Au, OSP, etc.) can be applied without special issue or consideration. A bake, as was described prior to soldermask application, should be performed prior to HASL or reflow exposures.

Final Circuitization: Individual circuits can be routed, punched, or lased depending upon preference, tolerances, and edge quality requirements. Parameters for routing are provided below:

Chip Load:	0.00125" to 0.00250"/rev 32mm – 64 mm/rev
Speed:	200-300 sfm 61-92 m/min
Peripheries:	Conventional cut Internal cut-outs climb cut
Tool type:	Carbide double fluted spiral-up endmill
Exit/Entry:	Phenolic or composite board
Tool life:	20-30 linear feet 6-9 meters

Pre-rout vacuum channels in backer board.

Double pass (opposite directions) when cleanest edge quality is required.

The information in this data sheet is intended to assist you in designing with Rogers' circuit materials. It is not intended to and does not create any warranties express or implied, including any warranty of merchantability or fitness for a particular purpose or that the results shown on this data sheet will be achieved by a user for a particular purpose. The user should determine the suitability of Rogers' circuit materials for each application.

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